

# Facile preparation of double-sided VO<sub>2</sub> (M) films with micro-structure and enhanced thermochromic performances

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## ABSTRACT

The fundamental challenge for VO<sub>2</sub>-based thermochromic smart windows is the ideal combination of high luminous transmittance ( $T_{lum}$ ) and high solar modulate ability ( $\Delta T_{sol}$ ). Satisfying these competing demands is commonly achieved by sacrificing the luminous transmittance by optimizing the thickness through doping, composition, porosity adjustment, bio-antireflection, and multi-layer design. Here, we demonstrate an effective strategy for the preparation of VO<sub>2</sub> (M) films on two sides of fused silica substrates with ice crystals like micro-structure, which play a key role in anti-reflection. The films have been prepared using a dip-coating method followed by annealing in argon atmosphere. The resulting micro-patterned VO<sub>2</sub> (M) films show an ultrahigh  $T_{lum}$  (75.5%) and a suitable  $\Delta T_{sol}$  (7.7%), derived from the sub-wavelength micro-structure on two sides of the substrate. In addition, the effects of the thickness, single-, or double-sided patterns on the optical performances of the VO<sub>2</sub> (M) films have also been investigated. These encouraging results show great potential for developing thermochromic smart windows with high performance for practical applications.

## 1. Introduction

Non-renewable energy has almost been exhausted, while increasing carbon dioxide emissions are leading to global warming. Nearly 30–40% of primary energy is used to maintain thermal comfort in buildings, such as heating, cooling, lighting, and ventilation [1]. The management of solar irradiation using thermochromic thin-film coatings on building glass (namely smart windows) can significantly decrease the energy consumption of buildings.

An ideal smart window needs a high transmittance in the visible region and performs thermal control ability to regulate the solar radiation in the near infrared (NIR) region [2]. Vanadium dioxide has a significant advantage as a coating material because of its insulator-metal transition (IMT), known as the thermochromic property, which changes from monoclinic phase with IR-transparent as a semiconductor to rutile phase that reflects IR as metal around 341 K [3].

Typically, the main optical performances of VO<sub>2</sub> thermochromic smart windows, including luminous transmittance ( $T_{lum}$ , 390–780 nm) and solar modulate ability ( $\Delta T_{sol}$ , 250–2500 nm), are obtained using the following equations:

$$T_{lum/sol} = \int \phi_{lum/sol}(\lambda) T(\lambda) d\lambda / \int \phi_{lum/sol}(\lambda) d\lambda \quad (1)$$

$$\Delta T_{sol} = T_{sol}(30^\circ C) - T_{sol}(100^\circ C) \quad (2)$$

where  $T(\lambda)$  is the recorded film transmittance,  $\phi_{lum}$  is the standard luminous efficiency function for the photopic vision of human eyes, and  $\phi_{sol}$  is the solar irradiance spectrum for air mass 1.5 (corresponding to the sun at 37° above the horizon).

Unfortunately, for thermochromic VO<sub>2</sub>-based films, it is difficult to achieve a sufficiently high  $T_{lum}$  while preserving the  $\Delta T_{sol}$  [4]. It has been calculated that the VO<sub>2</sub> (monoclinic M) film has a noticeable solar energy modulation limit of  $T_{lum} \sim 40\%$ , and the modulation of  $\Delta T_{sol}$  does not exceed  $\sim 10\%$  [5]. In order to increase the energy efficiency, several approaches have been designed to improve the optical performance of VO<sub>2</sub>, including doping [6–9], composition [10–14], porosity adjustment [15–17], bio-antireflection [18] and multi-layer design [19–21]. Although the above solutions show excellent results in enhancement of  $\Delta T_{sol}$ ,  $T_{lum}$  is still not high enough to achieve daylight quality in commercial buildings, which will increase the lighting energy needs, thus, resulting in negative energy conservation from a practical point of view [22,23].

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Recently, VO<sub>2</sub> (M) films with sub-wavelength structures have been widely investigated to enhance T<sub>lum</sub> by reducing the reflection at the interface between air and VO<sub>2</sub> (M) as a low effective-index (n) layer [18,24–28]. For example, Long et al. prepared VO<sub>2</sub> (M) films with moth-eye structures, which had a gradient refractive index and enhanced both  $\Delta T_{\text{sol}}$  and T<sub>lum</sub> [18]. Gao et al. investigated a series of VO<sub>2</sub> (M) films fabricated by polymer assisted sol-gel method [15,16,24,29], and a surface with micro-roughness was obtained by phase separation, which lowered the optical constants and resulted in excellent optical performance [24]. Zhou et al. introduced a periodic porous structure into a VO<sub>2</sub> (M) film. The pores allowed light to pass through directly, and a favorable  $\Delta T_{\text{NIR}}$  at 2000 nm with only a little attenuation of T<sub>vis</sub> was achieved [25]. Zhang et al. synthesized a self-assembled 2D ordered VO<sub>2</sub> (M) film using a hydrothermal method, and an increased  $\Delta T_{\text{sol}}$  of 10.7% with a T<sub>lum</sub> of 46.7% was achieved [26]. Tao et al. prepared porous W-doped VO<sub>2</sub> films with simultaneously enhanced visible transparency and thermochromic properties. The method is facile and impressive [27,28].

However, to the best of our knowledge, there is no research reports on the construction of micro-patterned VO<sub>2</sub> (M) film on two sides of the substrates, which will have a better anti-reflection effect [30–32], thus, obtaining simultaneous enhancement in  $\Delta T_{\text{sol}}$  and T<sub>lum</sub>.

Here, for the first time, we have prepared VO<sub>2</sub> (M) films with micro-structure on both sides of a fused silica substrate by a one-step dip-coating method, followed by annealing in argon atmosphere. The surface morphology of the VO<sub>2</sub> (M) film was ice crystal-like after annealing at 500 °C for 5 h. As expected, the T<sub>lum</sub> of the micro-patterned and double-sided VO<sub>2</sub> (M) film increased significantly, up to 75.5%, with a comparable  $\Delta T_{\text{sol}}$  of 7.7%.

## 2. Experimental details

### 2.1. Materials

V<sub>2</sub>O<sub>5</sub> powder (AR, Tianjin Fu Chen Chemical Reagents Factory) was used as the starting material to prepare the precursor sol. Polyvinylpyrrolidone (PVP K30, Sigma-Aldrich) was used as a sol stabilizer. All the reagents were used without further purification.

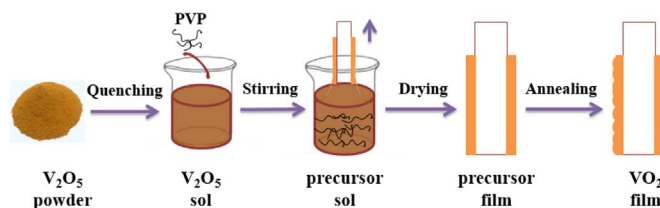
### 2.2. Preparation of the precursor sol

V<sub>2</sub>O<sub>5</sub> sol was fabricated by a water quenching method: 10.0 g V<sub>2</sub>O<sub>5</sub> powder was placed in a crucible and melted at 850 °C for 10 min. The fused V<sub>2</sub>O<sub>5</sub> liquid was added to 400 mL de-ionized (DI) water at room temperature (RT). The obtained slurry was stirred vigorously for 1 h, and then, diluted with DI water to 10 g/L. PVP (K30 6 wt%) was added to the sol to stabilize the V<sub>2</sub>O<sub>5</sub> sol at room temperature. The precursor sol was obtained after vigorous stirring for 10 h. The concentration of the precursor sol was adjusted from 2.5 g/L to 10.0 g/L to regulate the thickness by adding DI water. All the samples used in this work were synthesized using these precursor sols, unless otherwise noted.

### 2.3. Fabrication of the VO<sub>2</sub>-based film

The VO<sub>2</sub> films were dip-coated on fused-silica substrates (1×4 cm<sup>2</sup>) using a dip coater (KSV Instruments) at a speed of 500 μm/s. After drying at RT for 30 s, the same process was repeated 4 times. The smooth precursor films were then dried for 30 min at 80 °C to remove the excess solvent. Then, the films were annealed under argon atmosphere (purity of 99.99%) at different conditions to transform the V<sub>2</sub>O<sub>5</sub> phase into the VO<sub>2</sub> (M) phase. The annealing temperature was varied from 400 °C to 550 °C with an interval of 50 °C at the rate of 1 °C/min. The annealing time was 1 h, 5 h, and 10 h. Pretreatment was performed at 260 °C for 1 h to obtain smooth films. The general fabrication process is illustrated in Scheme 1.

Single sided VO<sub>2</sub> films were also prepared for comparison by



**Scheme 1.** Schematic illustration for the preparation of the micro-patterned VO<sub>2</sub> (M) films on both sides of the fused-silica substrates.

**Table 1**

Samples prepared in the experiment.

Samples	Sol concentration g/L	Annealing Temperature °C	Annealing time h	Film sides	No. of dips
D1	10.0	400	1	2	4
D2	10.0	400	5	2	4
D3	10.0	400	10	2	4
D4	10.0	450	1	2	4
D5	10.0	450	5	2	4
D6	10.0	450	10	2	4
D7	10.0	500	1	2	4
D8	10.0	500	5	2	4
D9	10.0	500	10	2	4
D10	10.0	550	1	2	4
D11	10.0	550	5	2	4
D12	10.0	550	10	2	4
D13	2.5	500	5	2	1
D14	5.0	500	5	2	1
D15	7.5	500	5	2	1
D16	10.0	500	5	2	1
D17	5.5	500	5	2	1
S17	5.5	500	5	1	1

washing out one side with DI water. The samples prepared are listed in Table 1.

### 2.4. Measurements

The crystalline phases of the films were determined using X-ray diffraction (XRD, PANalytical B.V. Model X'pert Pro, primary monochromatic Cu-Kα radiation) at an X-ray grazing angle of 2.0°. Surface morphologies and thickness of the films were examined by a field-emission scanning electron microscope (FEI Helios Nanolab600i) and an atomic force microscope (AFM, Dimension Icon, Bruker). Fourier transform infrared (FT-IR) spectroscopy was performed using a FT-IR system (VERTEX-70, Bruker) from 4000 to 400 cm<sup>-1</sup>. X-ray photoelectron spectroscopy (XPS) was performed with a PHI 5700 ESCA System using Al Kα radiation (1486.6 eV). XPS data were calibrated to the C1s peak and analyzed using Casa XPS software. Thermogravimetry-differential thermal analysis (TG-DTA) was performed using a NETZSCH STA449F3 at a heating rate of 10 °C/min in argon atmosphere.

The transmittance of the VO<sub>2</sub> films was measured using a UV–vis–NIR spectrophotometer (Lambda-950, Perkin Elmer) equipped with a film heating unit over the wavelength range of 250–2500 nm. Hysteresis loops were measured by collecting the transmittance of films at a fixed wavelength (2000 nm) at an approximate interval of 2.0 °C using a fiber optic spectrometer (Ocean optics, NIRQuest 256-2.5). The temperature was measured with a thermocouple in contact with the film and was controlled by a temperature-controlling unit. The temperature errors were smaller than 0.5 °C based on repeated measurements.

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